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**RESPONSE UNDER 37 C.F.R. 1.116  
EXPEDITED PROCEDURE--EXAMINING GROUP 2134**

Attorney's Docket No. 5308-157IP2

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re: Das et al.	Confirmation No.: 3570
Serial No.: 10/045,542	Group Art Unit: 1762
Filed: October 26, 2001	Examiner: Kirsten Jolley
For: METHOD OF FABRICATING AN OXIDE LAYER ON A SILICON CARBIDE LAYER UTILIZING AN ANNEAL IN A HYDROGEN ENVIRONMENT	

Date: July 18, 2005

Mail Stop AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**REQUEST FOR RECONSIDERATION**

Sir:

Applicants provide the present Request for Reconsideration to address the issues raised in the Final Official Action mailed May 18, 2005.

It is not believed that an extension of time and/or additional fee(s)-including fees for net addition of claims-are required, beyond those that may otherwise be provided for in documents accompanying this paper. In the event, however, that an extension of time is necessary to allow consideration of this paper, such an extension is hereby petitioned under 37 C.F.R. §1.136(a). Any additional fees believed to be due in connection with this paper may be charged to our Deposit Account No. 50-0220.

While no amendments to the claims have been made, a Listing of Claims is provided for the Examiner's convenience and begins on page 2 of this paper.

Remarks begin on page 5 of this paper.